

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

ROGER Y. LEUNG, ET AL.

Docket: H0002489 (4780)

Scrial Number: 10/507,410

Group Art Unit: 1792

Filed: September 13, 2004

Examiner: Erma C. Cameron

For: LOW METAL POROUS SILICA DIELECTRIC FOR INTEGRAL CIRCUIT

APPLICATIONS

AMENDMENT AFTER ALLOWANCE UNDER 37 C.F.R. 1.312

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Notice of Allowance mailed March 17, 2008, please amend the above-identified patent application as follows: